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(54) **PLURAL RESISTANCE-CAPACITANCE (PRC) ELECTRICAL DISCHARGE MACHINING SYSTEM**

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(57)

ABSTRACT

The present invention provides a plural resistance-capacitance (PRC) electrical discharge machining system comprising a control module, a digital electronic module, a driving module, and a discharge module. The control module allows the user to input a command and output a control signal accordingly. The digital electronic module processes the control signal and outputs a sequence signal to the driving circuit. The driving module amplifies the sequence signal and then outputs a driving signal to the discharge module. The discharge module then controls and drives a plurality of transistors to open circuits and break circuits according to the driving signal for controlling the charging and discharging of a plurality of capacitors of the discharge module in the electrical discharge machining. The present invention can increase the amount of discharge in a machining process, and improves the efficiency thereof.

9 Claims, 6 Drawing Sheets

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(58) **Field of Classification Search**

CPC B23H 1/022; B23H 2300/20; B23H 1/02
See application file for complete search history.

